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Perfect light trapping in nanoscale thickness semiconductor films with resonant back reflector and spectrum-splitting structures

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The optical absorption of nanoscale thickness semiconductor films on top of light-trapping structures based on optical interference effects combined with spectrum-splitting structures is theoretically investigated. Nearly perfect absorption over a broad spectrum range can be achieved in < 100 nm thick films on top of one-dimensional photonic crystal or metal films. This phenomenon can be attributed to interference induced photonic localization, which enhances the absorption and reduces the reflection of the films. Perfect solar absorption and low carrier thermalization loss can be achieved when the light-trapping structures with wedge-shaped spacer layer or semiconductor films are combined with spectrum-splitting structures.

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To reduce carbon dioxide release and cope with the increasing energy demand, photovoltaic solar cells have attracted significant attention. However, the cost efficiency and power conversion efficiency of solar cells is still relatively low. The high cost is mainly due to the use of expensive semiconductor materials, such as thick crystalline silicon films [1, 2]. The efficiency is primarily limited by thermalization loss [1–3].

A best way to enhance cost efficiency is to reduce solar cells to nanoscale [2, 4–9] to reduce material usage. In solar cells, the carrier collection length should be shorter than the carrier diffusion length (i.e., the distance travelled by a carrier before recombination). Thus nanoscale solar cells can use low-cost materials with lower carrier diffusion length (e.g., CuO, FeS2, and organic materials) to further reduces the cost [4]. However, nanoscale materials are usually too thin to completely absorb the solar light. Plasmon, photonic crystal, and quasi-random nanostructures can enhance absorption [4, 10–20]. Many theoretical and experimental works on interference-based light-trapping structures have demonstrated further improvement of the absorption of ultra-thin films compared with traditional light-trapping structures [21–23] at the cost of reduced working frequency range. Perfect broadband absorption is still difficult to achieve in these structures.

Carrier thermalization loss results from energy mismatch between the photon energy $E_\omega = \hbar\omega$ and the bandgap of semiconductors E_g [1–3]. Photons with energy below the bandgap of semiconductors are not absorbed, while photons with energy above the bandgap can create only a maximum open-circuit voltage V_{oc}. The excess energy $E_\omega - eV_{oc}$ is converted to heat loss, where e is the electron charge [1–3]. Multijunction solar cells can reduce carrier thermalization loss with increased number of junctions. However, only 2- and 3-junction solar cells can be used for industrial production due to the limitation of lattice matching and current matching requirement [2, 3]. Another widely studied and demonstrated technque to reduce the thermalization loss is to use side-by-side subcells and a spectrum-splitting structure [3, 24–26], which directs solar light of different wavelengths to different subcells with different bandgaps E_g. The thermalization loss can be reduced to approximately 10% by using 8-10 different subcells [3].

In this letter, we show that by combining two distinct well-established techniques, the interference-based light-trapping structures and the spectrum-splitting structure, perfect broadband solar absorption can be achieved in nanoscale thickness semiconductor films (SFs). First, for the 32nm GaAs films on top of a light-trapping structure, numerical and analytical results show narrow-band resonant absorption exceeding 90% ($\sim$ nine times larger than that of suspended GaAs films) as a result of photon localization. Second, we match the resonant absorption of the light-trapping structure with the spectrum-splitting structure by using wedge-shaped spacer layer or

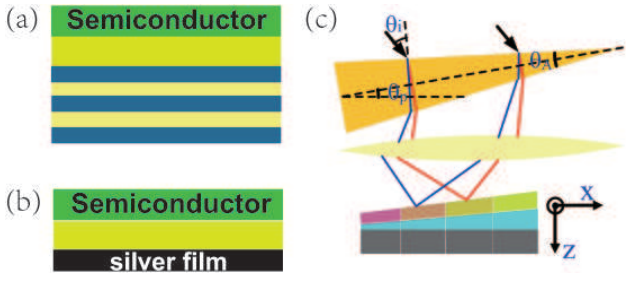

FIG. 1. (Color online) Schematic of SFs on (a) 1DPC and (b) Ag films with a spacer layer. (c) Schematic of spectrum-splitting structure combined with light-trapping structure.

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SFs and demonstrates perfect broadband solar absorption in $30-240$ nm thick SFs.

The light-trapping structure consists of a SF on top of a spacer layer and a one-dimensional photonic crystal (1DPC) [Fig. 1(a)] or 130 nm thick Ag film [Fig. 1(b)] at the bottom as the resonant back reflector. As demonstrated previously, such structure without wedge-shaped spacer layer or SFs can greatly enhance the absorption of graphene, MoS_2, and ultra-thin SFs within a certain wavelength region[22, 23, 27–32]. We also should point out the physical mechanism is different with the proposed structures consisting of thick SFs on photonic crystal [33, 34]. The optical interference effects in thick SFs are unimportant due to the strong absorption and an antireflection coating layer must be used to reduce the reflection. The 1DPC is composed of 8.5 periods of alternating doped ZnS and SiO_2 layers. The refractive indices of ZnS and SiO_2 at $\lambda = 550$ nm are $n_{ZnS} = 2.59$ and $n_{SiO_2} = 1.55$, respectively. The permittivities for silver film and SFs are frequency dependent [35, 36]. All layers are nonmagnetic ($\mu = 1$). The thickness of the ZnS (SiO_2) layers is $\lambda_{pcs}/4n_{ZnS}$ ($\lambda_{pcs}/4n_{SiO_2}$), where λ_{pcs} is the center wavelength. The spectrum-splitting structure is composed of a dense flint ZF13 prism and a low-dispersion convex lens [Fig. 1(c)]. The refractive indices for ZF13 glass is $n^2_{ZF13} = z_{g1} - z_{g2}\lambda^2 + z_{g3}\lambda^{-2} + z_{g4}\lambda^{-4} - z_{g5}\lambda^{-6} + z_{g6}\lambda^{-8}$, where $z_{g1} = 3.05344$, $z_{g2} = 1.2752 \times 10^{-2}$, $z_{g3} = 4.0609 \times 10^{-2}$, $z_{g4} = 2.2706 \times 10^{-3}$, $z_{g5} = 7.8087 \times 10^{-5}$, and $z_{g6} = 1.9874 \times 10^{-5}$.

To model the absorption of SFs in this structure, the standard transfer matrix method is used [28, 32]. In the lth layer, the electric field of the TE mode light with incident angle θ_i is given by

$$\mathbf{E}_l(z,y) = \left[A_l e^{ik_{lz}(z-z_l)} + B_l e^{-ik_{lz}(z-z_l)}\right] e^{ik_{ly}y}\mathbf{e}_x, \quad (1)$$

and the magnetic field of the TM mode in the lth layer is given by

$$\mathbf{H}_l(z,y) = \left[A_l e^{ik_{lz}(z-z_l)} + B_l e^{-ik_{lz}(z-z_l)}\right] e^{ik_{ly}y}\mathbf{e}_x, \quad (2)$$

where $k_l = k_{lr} + ik_{li}$ is the wave vector of the light, $\mathbf{e}_x$ is the unit vectors in the x direction, and z_l is the position of the lth layer in the z direction.

The electric fields of TE mode or the magnetic fields of TM mode in the (l+1)th layer are related to the incident fields by the transfer matrix utilizing the boundary condition

$$\begin{pmatrix} A_{l+1} \\ B_{l+1} \end{pmatrix} = \begin{pmatrix} T_{11} & T_{12} \\ T_{21} & T_{22} \end{pmatrix} \begin{pmatrix} A_0 \\ B_0 \end{pmatrix}. \quad (3)$$

Thus, we can obtain the absorbance of lth layer $\mathcal{A}_l$ using the Poynting vector $\mathbf{S} = \mathbf{E} \times \mathbf{H}$ [28, 32]

$$\mathcal{A}_l = [\mathcal{S}_{(l-1)i} + \mathcal{S}_{(l+1)i} - \mathcal{S}_{(l-1)o} - \mathcal{S}_{(l+1)o}]/\mathcal{S}_{0i}, \quad (4)$$

where $\mathcal{S}_{(l-1)i}$ and $\mathcal{S}_{(l-1)o}$ [$\mathcal{S}_{(l+1)i}$ and $\mathcal{S}_{(l+1)o}$] are the incident and outgoing Poynting vectors (l-1)th [(l+1)th] layer, respectively, $\mathcal{S}_{0i}$ is the incident Poynting vectors in air. For a perfect reflecting mirror without a spacer layer, straightforward algebra gives the absorptance

$$\mathcal{A}_{po} = 1 - |(1+\gamma_{sm})/(1-\gamma_{sm})|^2, \quad (5)$$

where $n_{sm}\gamma_{sm} = (1-\mathfrak{p}^2)/(1+\mathfrak{p}^2)$; $\mathfrak{p} = e^{ik_{sm}d_{sm}}$; n_{sm} and d_{sm} are the refractive index and thickness of SFs, respectively; and k_{sm} is the wave vector in the SFs. For thick metal film mirrors without the spacer layer, the absorptance

$$\mathcal{A}_{mf} = 1 - |1 - \xi_{sm} - \zeta_{sm}|^2 - n_{sm}|\xi_{sm}\mathfrak{p} + \zeta_{sm}\mathfrak{p}^*|^2, \quad (6)$$

where $\xi_{sm} = 2n_{21}\mathfrak{p}^2/(n_{21}n_{10}\mathfrak{p}^2 - n_{01}n_{12})$, $\zeta_{sm} = 2n_{12}/(n_{12}n_{01} - n_{10}n_{21}\mathfrak{p}^2)$, $n_{21} = n_{mf} - n_{sm}$, $n_{12} = n_{mf} + n_{sm}$, $n_{10} = 1 - n_{sm}$, and $n_{01} = n_{sm} + 1$, n_{mf} are the refractive indices of metal films.

For the spectrum-splitting structure, the angle of refraction of light through a prism is given by

$$\sin[\theta_{rp}(\lambda)] = \sin\{\theta_A - \arcsin[\sin(\theta_{ip})/n_{ZF13}(\lambda)]\} n_{ZF13}(\lambda), \quad (7)$$

where θ_A is the prism vertex angle, θ_{ip} is the light incidence angle to the prism. The the light incidence angle to the convex lens is $\theta_{il}(\lambda) = \theta_{rp}(\lambda) - \theta_A/2 - \theta_p$, where θ_p is the prism tilt angle. For perfect lens, the light are focused at $x(\lambda) = f_0 \tan[\theta_{il}(\lambda)]$, where f_0 is the focal length of the lens. For actual convex lens with aberrations, each of the refraction of light through the lens can be solved numerically using the Snell's Law.

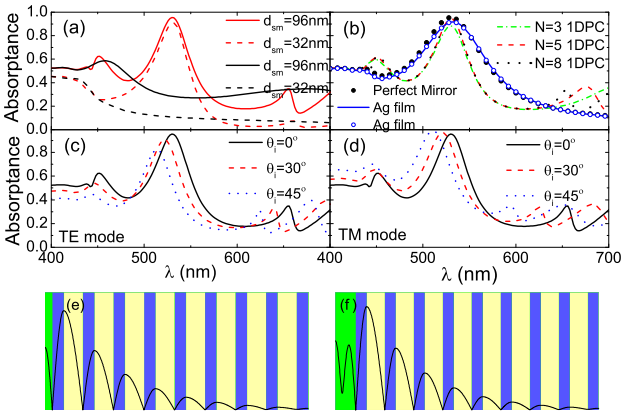

FIG. 2. (Color online) (a) Absorptance of different thickness GaAs films without a spacer layer as a function of wavelength for suspended GaAs films (black line) and GaAs films with a 1DPC (red or grey line). (b) Absorptance of 96 nm GaAs films on 1DPC as a function of wavelength with different period numbers N of 1DPC. The black solid-circle curve shows the absorptance of 96 nm GaAs films with the perfect reflection mirror. The blue solid line and blue open circle curve shows the absorptance of 78 nm GaAs films on Ag films. The absorptance of 96 nm GaAs films on a 1DPC as a function of light wavelength for different incident angles for (c) TE mode and (d) TM mode. Optical field distribution in (e) 32 and (f) 96 nm GaAs films on 1DPC.

As shown in Fig. 2(a), for 32 nm (96 nm) GaAs films, the maximum absorbance at the resonant wavelength $\lambda = 530$ nm of solar radiation is improved by the 1DPC from ∼10.8% (28.4%) for suspended films to ∼90.8% (95.5%) even without antireflection coating layers. The magnitude of the enhancement is much larger than that of thick SFs on photonic crystal even with antireflection coating layers[33, 34]. This is because the SFs act as a 1D surface defect that leads to localization on the surface due to interference effects [Figs. 2(e) and 2(f)], thereby reducing the reflection and enhancing the absorption [28, 30, 32], similar to graphene and monolayer MoS_2 on top of 1DPC. As shown in Fig. 2(b), the 1DPC with increasing number N of periods has increasing reflectivity, photonic localization, and hence absorption. The SF resonant absorption with the 1DPC is close to that with a perfect reflection mirror (black solid circles) and slightly better than that with a Ag film (blue solid line and blue open circle), which has a lower reflectivity. However, the width of the resonant absorption for 1DPC is smaller than that for Ag film, due to the limited photonic band gap of the 1DPC. Away from the resonant absorption, the SF absorption on the Ag film almost coincides with that on a perfect reflection mirror.

For oblique light incidence, the large refractive index of GaAs ensures, by Snell's law, that the light propagation angle θ' in the GaAs film is small even with a large incident angle θ_i. Thus the resonant absorption wavelength $\propto \cos\theta'$ for the SFs on the 1DPC is less affected by the light incident angle [Figs. 2(c) and 2(d)] and favors the design of solar cells.

An essential ingredient of our proposal is the tunability of the resonant absorption wavelength λ_R of the light-trapping structure. As shown in Figs. 3(a) and 3(b), for the 1DPC, $\lambda_R = 4n_{sm}d_{sm}/(2m+1)$ ($m \in \mathbb{Z}$) decreases with decreasing SF thickness d_{sm}. This remains qualitatively true for the Ag film, since we still have the estimate $\lambda_R \sim 4n_{sm}d_{sm}/(2m+1)$. Another approach to tune λ_R is to insert a transparent (e.g., AlAs) spacer layer, e.g., for the 100 nm GaAs film on the 1DPC with $\lambda_{pcs} = 700$ and Ag films, λ_R almost linearly increases with the thickness of the spacer layer [Figs. 3(c) and 3(d)]. The spacer layer can also act as the buffer layer to enhance or reduce the lattice distortion of the SFs.

The problem with a given light-trapping structure is that enhanced absorption appears only within a certain range of wavelength. To cure this problem, we propose to combine it with the spectrum-splitting structure, which has been widely used experimentally to reduce the carrier thermalization loss in solar cells [3, 24–26]. With the spectrum-splitting structure, a dense flint ZF13 prism and a low-dispersion convex lens focuses solar light with different wavelengths onto different locations on the SFs of the light-trapping structure [Fig. 1(c)]. By appropriately choosing the species and thicknesses of SFs or the thicknesses of the spacer layers to match the solar wavelength on each location (i.e., use the wedge-shaped spacer layer or SFs), perfect absorption can be achieved

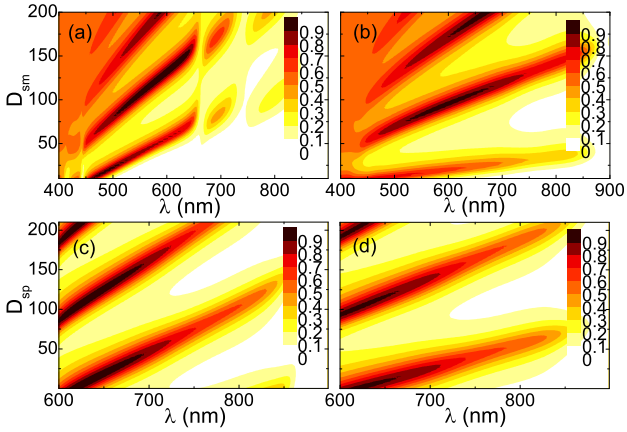

FIG. 3. (Color online) Contour plots of the absorptance of the GaAs films on (a) 1DPC and (b) Ag films without spacer layers as a function of light wavelength and thickness of GaAs films with $\lambda_{pcs} = 550$ nm. Contour plots of the absorptance of 100 nm GaAs films on (c) 1DPC and (d) Ag films as a function of light wavelength and thickness of AlAs spacer layers.

for each wavelength. Since the slope of the SFs is smaller than 2.5×10^{-5}, the SF surface can be treated as parallel planes at each point. Thus, the transfer matrix method can be used in the calculation. The parameters include [Fig. 1(c)]: the prism vertex angle $\theta_A = 30°$, the light incidence angle $\theta_i = 26.4°$ (the refracted light in the prism is parallel to bottom plane of the prism), the prism tilt angle $\theta_p = 10°$ (the light is nearly parallel to z direction), and the refractive indices and spherical radius of the convex lens are 1.5 and 0.6 m, respectively. CdS ($E_g = 2.42$ eV), $Ga_{0.5}In_{0.5}P$($E_g = 1.9$ eV), GaAs($E_g = 1.42$ eV), and $In_{0.53}Ga_{0.47}As$ ($E_g = 0.86$ eV) films consist of side-by-side SFs.

Numerical results are shown in Fig. 4. When the thickness of SFs perfectly matches the spectrum splitting with various λ_{pcs} (i.e., for lights with wavelength λ_0 focused at $x = x_0$ point, the SF thickness at $x = x_0$ is chosen to obtain maximum absorption), the absorption of side-by-side SFs is almost always $> 90\%$ and the maximum absorption can be $> 99\%$. Furthermore, more types of SFs can be used in this structure because the lattice matching and current matching requirements are not restricted. Thus, the proposed structures can significantly reduce carrier thermalization loss. Apart from applications in solar cells, perfect wide-range absorption can also have applications in optoelectronic devices, such as photoelectric detectors. Different for nanowire array solar cells, the proposed structures have low surface recombination loss. For SFs with linearly varied thickness [solid line in the inset of Figs. 4(a) and 4(b)], only the absorption of $In_{0.53}Ga_{0.47}As$ film significantly decreases because the dispersion of ZF13 glass is too small to effectively separate different-wavelength lights within this wavelength range.

The influence of lens aberrations on SFs absorption is shown in Figs. 4(c) and 4(d). An actual convex lens

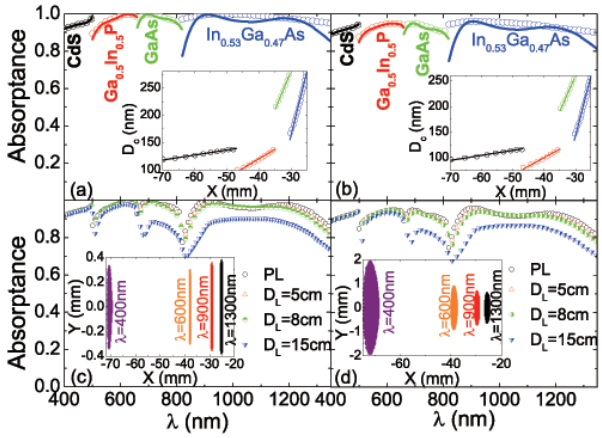

FIG. 4. (Color online) Absorptance of side-by-side SFs on (a) 1DPC and (b) Ag films for the SFs with thickness that perfectly match the spectrum-splitting structure (open circle curves) and for SFs with linearly varying thicknesses (solid lines). The inset shows the thickness of side-by-side SFs as a function of the x coordinate. The absorptance of side-by-side SFs on (c) 1DPC and (d) Ag films with perfect lens (black open circle curves) and convex lens with different diameters D_L. The inset in (c) and (d) shows a focused light spot for different wavelengths for $D_L = 8$ cm and $D_L = 15$, respectively.

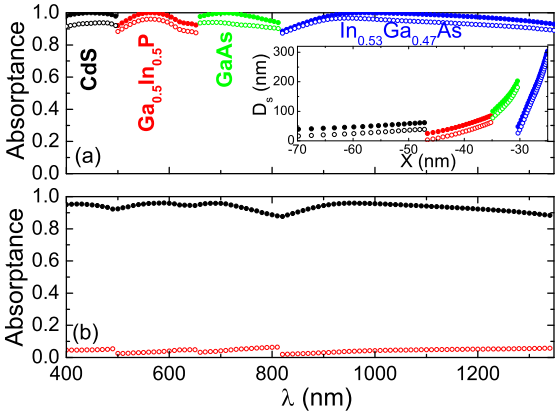

FIG. 5. (Color online)(a) Absorptance of SFs on 1DPC (solid circle curves) and Ag films (open circle curves) combined with spectrum-splitting structure with various spacer layer thickness. The inset shows the spacer-layer thickness as a function of the x coordinate. (b) Absorptance of SFs (black solid circle curves) and indium tin oxide films (red open circle curves) on 1DPC.

cannot focus parallel light to a perfect point because of lens aberrations, which increase with increased lens diameter D_L [inset of Figs. 4(c) and 4(d)]. Lens aberrations reduce the light-trapping effect because obtaining the maximum absorption from the entire whole focused light spot is difficult by varying the thickness of SFs. The influence of lens aberrations is reduced when spectrum-splitting structure with strong dispersion ability is used. The changes in SFs absorption are very small for $D_L < 8$ cm. The absorption of GaAs and $In_{0.53}Ga_{0.47}As$ significantly decreases for $D_L = 15$ cm because of the low dispersion of ZF13 glass within the long wavelength range.

Perfect absorption can be achieved in the full solar spectrum by varying the spacer-layer thickness. Side-by-side SFs consist of 80 nm CdS, 80 nm $Ga_{0.5}In_{0.5}P$, 240 nm GaAs, and 240 nm $In_{0.53}Ga_{0.47}As$ films. The refractive indices of a spacer layer is 2.6. The absorptance of SFs combined with spectrum-splitting structure can exceed 90% by varying spacer-layer thickness [Fig. 5(a)]. The thickness of SFs do not have to satisfy $d_{sm} = (2m+1)\lambda/4n_{sm}$. SFs with a large absorption coefficient can be thinner. The influence of indium tin oxide transparency electrode on top of SFs is shown in Fig. 5(b). The absorptance of 20 nm indium tin oxide films is about 5%, and the absorptance of SFs shows about 5% reduction.

Finally, we discuss on the fabrication techniques and the potential improvement of the proposed structures. The length of the subcells is about 0.5-2 cm. The subcells can be fabricated separately and then joined using fasteners, adhesive, or welding. In each subcells, for SFs on top of 1DPC (which can be regarded as a half of the semiconductor microcavity) or metal films with spacer layers, similar structure have been fabricated in experiments [22]. The difference in this letter is that the SFs or spacer layers are wedge-shaped layers, which can be grown by existing technology such as molecular beam epitaxy. As shown by J. P. Prineas et al.[37], to reduce the speed of light 210 wedge-shaped semiconductor layers are grown by molecular beam epitaxy. Even though strong light-trapping effects is observed in the proposed structures, to achieve perfect absorption in < 20 nm SFs, light-trapping structure with more strong photonic localization such as the microcavity should be used [38, 39]. For the proposed spectrum-splitting structure, dispersion ability within the long wavelength range is low because of the low dispersion of ZF13 glass that degrades performance. Prism and convex lens without an antireflection film can reflect about 10-15% solar light. Thus, various types of spectrum-splitting structure should be studied in the future [3, 24–26].

In conclusion, the optical absorption of SFs on top of 1DPC and Ag films combination with spectrum-splitting structure is investigated. In these structures, the maximum optical absorptance of <100 nm SFs can be $> 90\%$ because of photon localization. The absorption of SFs on 1DPC is less affected by the incident angle of light and can be tuned by varying thickness of the SFs and spacer layers. By using side-by-side nanoscale thickness SFs and combination with spectrum-splitting structure, perfect solar absorption can be achieved with low carrier thermalization loss. Our proposal can have significant applications in the development of ultra-thin and high-efficiency solar cells and in optoelectronic devices, such as photoelectric detector.

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